

Transport mechanism through metal-cobaltite interfaces

C. Acha*

Laboratorio de Bajas Temperaturas - Departamento de Física - FCEyN - Universidad de Buenos Aires and IFIBA - CONICET, Pabellón I, Ciudad Universitaria, C1428EHA Buenos Aires, Argentina.

A. Schulman†

Laboratorio de Bajas Temperaturas - Departamento de Física - FCEyN - Universidad de Buenos Aires and IFIBA - CONICET, Pabellón I, Ciudad Universitaria, C1428EHA Buenos Aires, Argentina. and Laboratoire des Matériaux et du Génie Physique, UMR 5628 CNRS-UDG-Grenoble INP, Minatec 3, Parvis Louis Néel, CS 50257, 38016 Grenoble, Cedex 1, France.

M. Boudard

Laboratoire des Matériaux et du Génie Physique, UMR 5628 CNRS-UDG-Grenoble INP, Minatec 3, Parvis Louis Néel, CS 50257, 38016 Grenoble, Cedex 1, France.

K. Daoudi

Department of Applied Physics and Astronomy, University of Sharjah, P.O. Box 27272, Sharjah, United Arab Emirates.

T. Tsuchiya

National Institute of Advanced Industrial Science and Technology (AIST), Ibaraki 305- 8565, Japan.

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Abstract

The resistive switching (RS) properties as a function of temperature were studied for Ag/La_{1-x}Sr_xCoO₃ (LSCO) interfaces. The LSCO is a fully-relaxed 100 nm film grown by metal organic deposition on a LaAlO₃ substrate. Both low and a high resistance states were set at room temperature and the temperature dependence of their current-voltage (IV) characteristics was measured taking care to avoid a significant change of the resistance state. The obtained non-trivial IV curves of each state were well reproduced by a circuit model which includes a Poole-Frenkel element and two ohmic resistances. A microscopic description of the changes produced by the RS is given, which enables to envision a picture of the interface as an area where conductive and insulating phases are mixed, producing Maxwell-Wagner contributions to the dielectric properties.

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Resistive switching (RS) has focused much attention in recent years for being the mechanism on which one of the most promising non-volatile memory device (RRAM or Memristor) is based.¹ Among all the investigated RRAM devices, based on a variety of materials and different mechanisms², those related to metal/perovskite oxides usually present a bipolar switching type³, whose origin can be associated with a voltage-driven oxygen vacancy migration near the interface.⁴ Depending on their metal/oxide interface, different scenarios have been considered to explain which are the particular effects at the atomic level produced by this ion reconfiguration. These scenarios were elaborated by analyzing the electrical transport behavior of the switching device, in order to reveal the mechanism behind their properties.⁵ Particularly, their isothermal current-voltage (IV) characteristics are useful to distinguish if the conduction of the device is related to the existence of an ohmic behavior ($I \sim V$), a space charge limited conduction (SCLC, $I \sim V^2$), or Poole-Frenkel (PF), Fowler-Nordheim (FN) or Schottky (Sch) emissions [$I \sim \exp(V^n)$]. For example, an electric-field-trap-controlled SCLC was proposed to explain the RS behavior of Ag/La_{0.7}Ca_{0.3}MnO_{3- δ} interfaces⁶, while for Au/YBa₂Cu₃O_{7- δ} , a PF conduction in a variable-range hopping scenario was considered, with a pulse-controlled-trap energy level.⁷

La_{1- x} Sr _{x} CoO_{3- δ} (LSCO) is one of the perovskite oxides with high oxygen mobility where the existence of RS has been put in evidence^{8,9}. In particular Fu et al.⁹ have recently investigated the RS on Ag/La_{0.5}Sr_{0.5}CoO_{3- δ} 200nm thick films grown by pulsed laser deposition on Pt/Ti/SiO₂/Si substrates, showing that their transport mechanism was controlled by a SCLC with traps exponentially distributed in energy ($I \sim V^m$, with $m=1;2;\geq 7$, depending on the different SCLC regimes explored).

In this work, RS and isothermal IV characteristics of Ag/LSCO interfaces are reported in two well differentiated low and high resistance states (LRS and HRS) in order to point out their microscopic differences. We propose an equivalent circuit model with a PF element and two ohmic resistances that reproduces the non-trivial electrical behavior of this memristor. Besides, we found that the metal/oxide interface may be composed by a nanometric mixture of conducting and insulating zones, yielding to an enhancement of the contact dielectric constant due to Maxwell-Wagner (MW) type contributions.

An epitaxial 100 nm thick film of La_{0.7}Sr_{0.3}CoO₃ (LSCO) was grown on a 10x10x0.5 mm³ LaAlO₃ (LAO) single crystal (001) substrate (Crystec) by using a conventional metal organic deposition process (with a final annealing at 1000 °C in air). A detailed descrip-

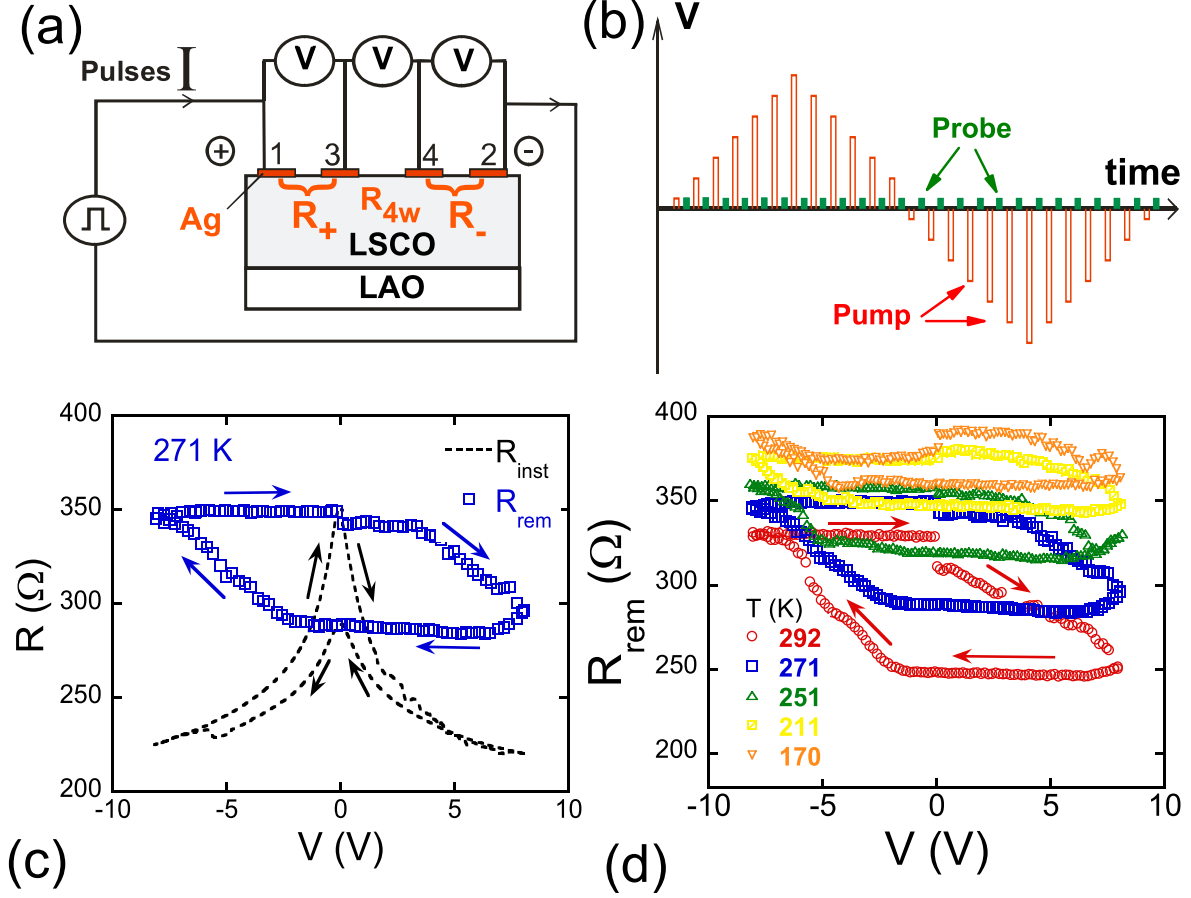


FIG. 1: (Color online) (a) Schematic representation of the device and its electrode configuration. (b) Voltage pump (red) and probe (green) protocol followed to measure the IV characteristics, the instantaneous (R_{inst}) and the remanent resistance (R_{rem}). (c) RHSL of both R_{inst} and R_{rem} measured at 271 K for a ± 8 V cycle. The existence of a non-volatile memory, two well differentiated LRS and HRS as well as non-linear effects can be observed. The arrows indicate the clockwise circulation of the cycle. (d) RHSL of R_{rem} at different temperatures.

tion of the growth process, phase purity, structural, morphological, magnetic and electric characterizations can be found in previous works.^{10,11} To perform electrical transport measurements, four hand-painted Ag electrodes were done on top of the surface of the film. The electrodes, depicted in Fig. 1(a), have approximately a width of 0.75 mm and a mean separation between them of 0.6 ± 0.1 mm .

The IV characteristics of the R_+ interface (including the interfacial zone plus a fraction of the bulk material between electrodes 1-3 (see Fig. 1(b)) were measured at different fixed temperatures using two synchronized Keithley 2400 precision source/measure units (SMU).

While one of the SMU provides 10 ms square voltage pump pulses to electrodes 1-2, with amplitude following the triangular shape shown in Fig. 1(b) in a ± 10 V range, and measures current (I) during the last 50% of the pulses period, where the signal remains practically constant (stationary regime), the other SMU measures the voltage drop between electrodes 1 and 3 (V13, hereafter noted as V). In this way, the instantaneous resistance of this interface can be defined as $R_{inst} = V/I$. After 300 ms of each pump pulse, a 10 ms probe pulse corresponding to a small bias voltage pulse (50 mV) was applied in order to measure in the same way the remnant resistance (R_{rem}) of the junction (see Fig. 1(b)). Then, after an additional waiting time of 300 ms, the cycle starts again with the following pump pulse.¹² The four wires resistance [$R_{4W}(T)$] of the LSCO sample was measured applying a small bias current (10 μ A) (Keithley 220 current source) to electrodes 1 and 2 and measuring V34 (Agilent 34430A nano-voltmeter). Temperature was stabilized with a stability better than 0.3% for each IV characterization in the $80 < T < 300$ K range and measured with a Pt thermometer well thermally anchored to the sample.

The existence of RS properties for our Ag/LSCO device was first checked by applying the pulsing protocol presented in Fig. 1(b) and by measuring its instantaneous and remnant response. These results can be observed in Fig. 1(c), where a typical resistance hysteresis switching loop (RHSL) is shown at $T \simeq 271$ K, where both, the instantaneous non-linear resistance (R_{inst}) and the remnant resistance (R_{rem}), are plotted as a function of the local voltage V applied during the pulsing protocol. A cyclic evolution of R_{rem} can be observed, between low and high values for pulses in the ± 8 V range and with a clockwise circulation. Within the voltage amplitude of these pulses, a reproducible ratio $\alpha = \frac{R_{rem}^{High}}{R_{rem}^{Low}} \simeq 1.3$ was obtained. As shown in Fig. 1(d), a similar behavior is obtained for the whole T range studied ($80 \text{ K} < T < 300 \text{ K}$), with a reduction of α to $\simeq 1.08$ with decreasing T .

In order to reveal the main conduction mechanism through the device and particularly the microscopic differences between the LRS and the HRS, the IV characteristics of the Ag/LSCO junction as a function of T should be measured in two stable and well differentiated states. To program these states and to facilitate this task, a higher $\alpha \sim 10$ was produced at room temperature ($R_{rem}^{Low} \sim 1 \text{ k}\Omega$; $R_{rem}^{High} \sim 10 \text{ k}\Omega$) by increasing the amplitude of the negative pulses up to -10 V (see the inset of Fig. 2(a)).

After generating each state, the voltage amplitude of the pulses during the IV measurement cycle was maintained sufficiently low in order to prevent a RS that would change the

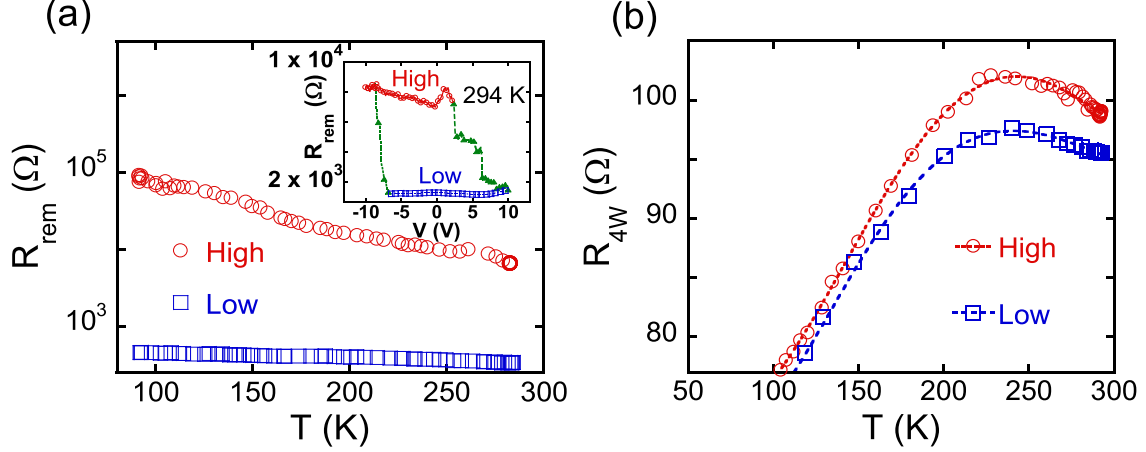


FIG. 2: (Color online) (a) Remnant resistance R_{rem} measured during each low-voltage IV cycle at different temperatures for each room-temperature-programmed LRS and HRS. The inset shows a typical RHSL of R_{rem} performed at room temperature to switch from one state to the other. (b) R_{4W} vs T measured for each programmed state.

microscopic characteristics that determine the properties of the device. From the RHSL of R_{rem} shown in Fig. 1(c) a safe voltage amplitude of $-1.5 \text{ V} < V < 1.0 \text{ V}$ was then chosen to perform the IV characteristics at different stabilized temperatures in the $80 \text{ K} < T < 300 \text{ K}$ range.

As can be observed in Fig. 2(a), R_{rem} was measured for both selected states before and after each IV measurement, for experiments performed at different temperatures. It is clear that no significant RS was produced along the entire series of IV measurements. The T dependence of R_{4W} for both states (Fig. 2(b)) shows the typical behavior measured before the pulsing treatments.¹¹ Surprisingly, the measured R_{4W} is different for each contact state, although R_{4W} is measured with contacts 3 and 4 (see Fig. 1(a)) located at a macroscopic distance ($\sim 1 \text{ mm}$) from the pulsed contacts 1-2. The increase of resistivity when switching from LRS to HRS is in accordance with a reduction of the local oxygen content.¹³ This indicates that the pulsing affects zones far away from the interfaces, as was previously observed¹⁴ in ceramic $\text{YBa}_2\text{Cu}_3\text{O}_7$ (YBCO), probably associated to the high mobility of oxygen in these oxides^{15,16} and to its relation to the mechanism of the resistance change induced by the pulsing treatment.⁴

The IV characteristics for both selected states are shown in Fig. 3. Both states show

non-linear effects. The LRS shows a small T dependence, while the HRS shows a higher sensitivity to it. A Schottky mechanism can be ruled out as no rectifying behavior can be observed. Details of the IV characteristics are more readily apparent if one considers the derivative $\gamma = d\ln(I)/d\ln(V)$ plotted as a function of $V^{1/2}$ (see Fig. 4).¹⁷ For clarity, only the increasing negative voltage part of the IV measurement cycle was used to plot these curves (taking the absolute value of V). Indeed, the typical conduction mechanisms through metal-oxide interfaces can be easily determined by analyzing these γ vs $V^{1/2}$ curves. This is the case for an ohmic, a Langmuir-Child or a SCLC conduction, that will all show a constant γ ($= 1, 1.5$ or 2 , respectively), or for a Schottky (Sch) or a Poole-Frenkel (PF) behavior that will be represented by a straight line differing in the intercept (0 for Sch, 1 for PF).⁵ Our results are described by a more complex γ vs. $V^{1/2}$ curve as it can be observed in Fig. 4. Both states show for low voltages a γ tending to a constant value close to 1 (more clearly defined for the HRS), then a small linear region limited by the appearance of a maximum (more prominent at low temperatures and for the HRS) and a final gradual decrease.

This complex behavior can be reproduced by considering the circuit elements depicted in the inset of Fig. 4(b). This representation of the memristor by a similar arrangement of circuit elements was already done in previous papers to describe the dynamical behavior of metal-YBCO interfaces¹⁸, and the IV characteristics of metal-manganite junctions.^{19,20}

We would like to note here that the data reported by Fu et al.⁹ on the IV characteristics

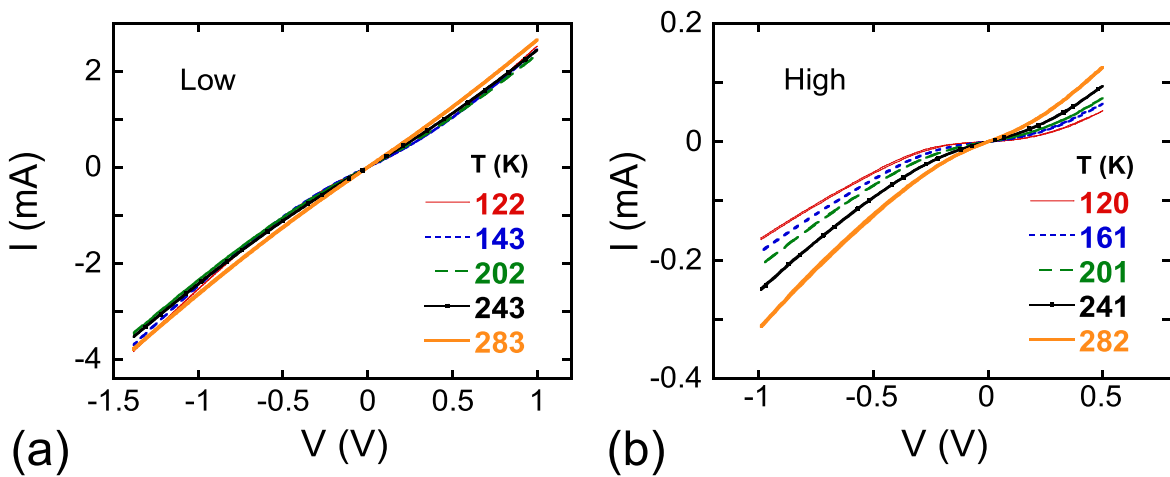


FIG. 3: (Color online) IV characteristics at different temperatures for (a) the LRS and (b) the HRS. Non-linear effects are clearly visible as well as a non-rectifying behavior.

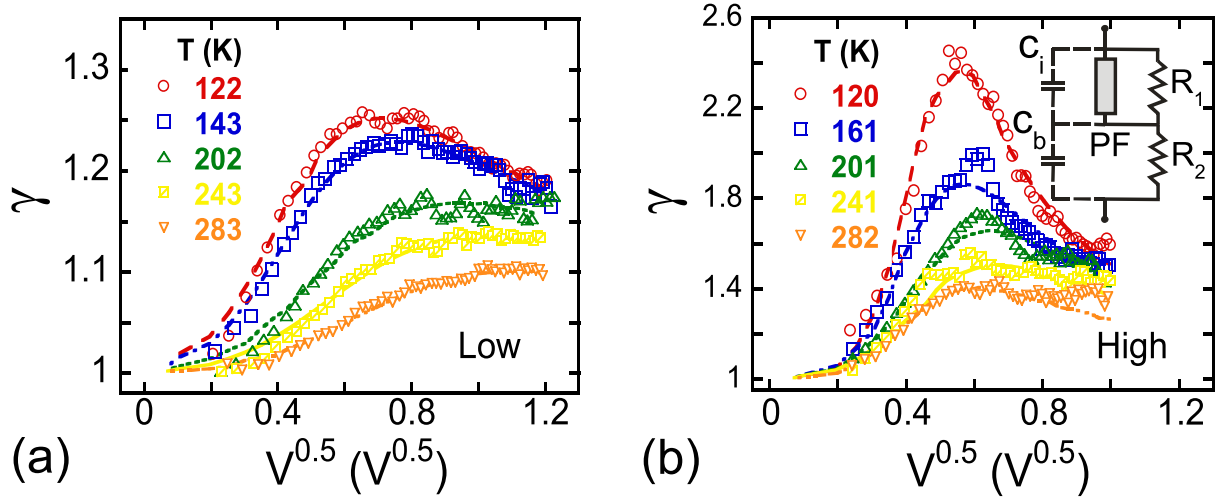


FIG. 4: (Color online) γ as a function of $V^{1/2}$ at different temperatures for the programmed (a) LRS and (b) HRS. The dashed-lines correspond to fits of the experimental data using Eq. 1. The inset is a schematic of the circuit elements used to model the IV characteristics.

of Ag/La_{0.5}Sr_{0.5}CoO_{3- δ} interfaces presents a similar $\gamma(V)$ behavior to the one reported here. Their γ evolves gradually with increasing V from 1 to a maximum value slightly higher than 2 and then decreases smoothly with further increasing V . Here, by considering the almost linear parts of the $\gamma(V^{0.5})$ curve and by discarding a Schottky conduction (as mentioned, due to the lack of rectifying behavior), the non-linear element was associated with a PF conduction. A parallel ohmic element (R_1) is needed to reproduce the quasi-ohmic dependence observed at low voltages, while the ohmic element in series (R_2) should be considered to limit the non-linear conduction, producing the maximum and the concomitant decrease of γ observed for higher voltages. In this way, the following equations represents the IV characteristics of the proposed representation for the Ag/LSCO memristor:^{5,21}

$$I = A (V - IR_2) \exp\left[\frac{B(V - IR_2)^{1/2}}{k_B T}\right] + \frac{V - IR_2}{R_1}, \quad (1)$$

with

$$A = \frac{\exp(-\frac{\phi_B}{k_B T})}{R_{ox}}, B = \frac{q^{3/2}}{(\pi \epsilon' d)^{1/2}}, R_{ox} = \frac{d}{Sq n_0 \mu}, \quad (2)$$

where T is the temperature, k_B the Boltzmann constant, ϕ_B the trap energy level, q the electron's charge, S the conducting area, ϵ' , n_0 and μ the real part of the dielectric constant, the density of carriers and their mobility in the oxide, respectively, and d the distance where the voltage drop is produced.

The dashed-lines plotted in Fig. 4 were obtained by fitting numerically the IV curves, by using the implicit Eq. 1. The non-trivial experimental $\gamma(V^{0.5})$ dependence is very well reproduced by the proposed model. Only a slight difference can be noted for the highest voltages in the HRS, where γ seems to saturate at a value close to 1.5 instead of the expected 1. This is possibly indicating the existence of a more complex process in parallel with R_2 , like a T -independent Langmuir-Child conduction due to ballistic carriers through vacuum voids or oxygen-depleted zones^{5,22}. More work is needed to address these deviations, which are beyond the scope of the present paper.

We reduced the four fitting parameters A , B , R_1 and R_2 to three by considering that R_1 and R_2 can be related to the measured $R_{rem}(T)$ using the fact that, for sufficiently low voltages, $R_{rem} \simeq R_1/(AR_1 + 1) + R_2$ (see Ref. 23 for a list of typical parameters obtained for each state). Fig. 5 shows the A , B^{-2} , R_1 , and R_2 parameters obtained from the fits. For both resistance states, a straight line is obtained when plotting $\ln(A)$ vs $1/T$, indicating that the exponential relation of A with $1/T$ derived from the PF conduction is valid (see Eq. 2). The slope, associated with the trap potential ϕ_B , indicates the presence of traps [$\phi_B/(k_B) \sim 900$ K] in the interfacial zone of the oxide for the HRS, while the flatness of the curve for the LRS points out practically their absence [$\phi_B/(k_B) \sim 60$ K]. Similar $\phi_B/(k_B)$ values (~ 700 - 1200 K) were obtained for Au/YBCO interfaces after pulsing treatments.⁷ In the same way, by analyzing the intercept, it can be derived that $R_{ox}^{HRS} \simeq 2R_{ox}^{LRS}$. This indicates that not only deeper traps are created when switching from LRS to HRS but also that the resistivity of the interfacial zone, where the PF conduction develops, increases, which is probably associated with an overall reduction of the local oxygen content.

The B parameter is plotted in Fig. 5(b) as B^{-2} times $q^3/(\pi\epsilon_0)$ vs T , in order to represent, according to Eq. 2, the T dependence of $\epsilon'_r d$, where $\epsilon'_r = \epsilon'/\epsilon_0$ (with ϵ_0 being the vacuum permittivity). As the distance d , associated with the interfacial zone, is expected to be T independent, and to remain practically unchanged for both states, as was reported for Au/YBCO⁷, the T dependence of ϵ'_r can be directly inferred from Fig. 5(b). It can be observed that ϵ'_r in the LRS increases with decreasing T , following a step-like shape, while in the HRS it shows a tendency to saturate for temperatures below 200 K. This non-usual dependence of ϵ'_r for a paraelectric oxide²⁴ was previously observed in the case of mixtures of conducting and insulating regions, which are in many cases generated intrinsically in metal-oxide interfaces²⁵. This mixture of phases may give rise to a Maxwell-Wagner (MW)

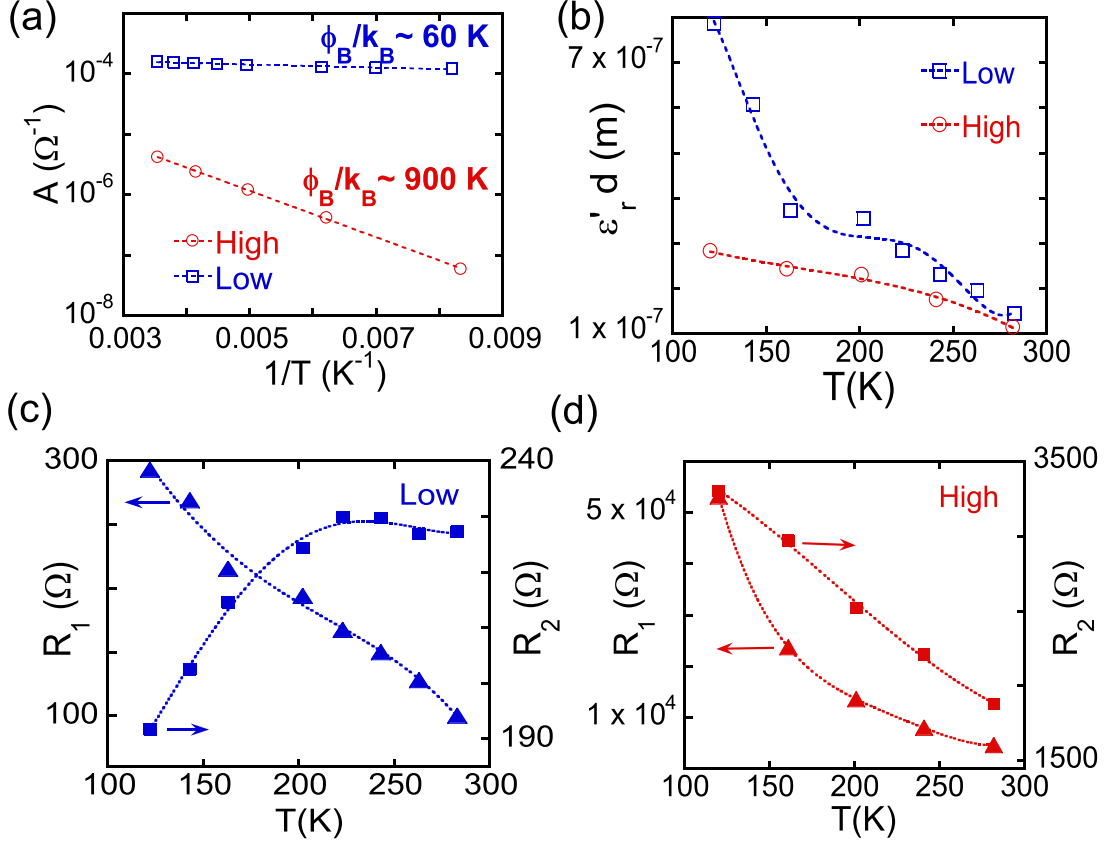


FIG. 5: (Color online) Parameters obtained from the fits of the experimental data presented in Fig. 3 for the LRS and the HRS by Eq. 1. (a) Semilogarithmic plot of A vs $1/T$. Dashed-lines are fits of the data by using Eq. 2. (b) $\epsilon'_r d$ vs T derived from the B fitting-parameter by using Eq. 2. The dashed lines are guides to the eye. (c) and (d) $R_1(T)$ and $R_2(T)$ for the LRS and the HRS, respectively. Dashed-lines are guides to the eye.

effect^{25,26}, where the charge carriers accumulate at the border of the conducting regions, which act as very small parallel-plate capacitors, representing a very high capacitance. In this particular case, by describing the sample as composed by an interfacial region in series with the bulk (each material with different conductivity and dielectric constant), it was shown that the dielectric constant has a frequency dependence described by the Debye relaxation laws, with a static value (ϵ'_s) higher than the one at high frequencies (ϵ'_∞) and a characteristic time (τ) that follows the T dependence of the resistivity of the bulk. A step in ϵ'_r to a higher value (a shift from ϵ'_∞ to ϵ'_s) is then predicted as τ is reduced when decreasing T . This is particularly what it can be observed in Fig. 5(b), as in the LRS ϵ'_r increases in correspondence to the decrease of R_2 (see Fig. 5(c), which represents the

electrical connection between the interfacial zone and the bulk. In contrast, as R_2 remains insulating in the HRS (see Fig. 5(d), the obtained ϵ'_r is weakly T dependent.

Finally, R_1 becomes 100 times more insulating in the HRS while R_2 , mimics the T dependence of the R_{4W} resistance in the LRS, but becomes semiconducting-like with a 10 times increase in the HRS. This similarity between $R_2(T)$ and $R_{4W}(T)$, only differing in a geometric constant that amplifies its value, was previously seen in metal interfaces with YBCO¹⁴ and manganites²⁷, pointing out the generality of this process.

All these results lead us to consider that, independently of the initial oxygen content of the oxide, the Ag/LSCO interfacial region has become an oxygen-depleted zone, where the electrical transport properties are dominated by the presence of charge carrier's traps (PF) in parallel with insulating regions (R_1). These interfacial characteristics may represent a common feature of other metal/perovskite oxide interfaces, like Au/YBCO, where a similar behavior was observed⁷, probably associated with the capacity of the metallic electrode to generate in the oxide the coexistence of conducting and insulating regions, yielding probably to a granular structure. This scenario would be similar to the one existing intrinsically for phase-separated manganites, where the coexistence of nanometric conducting and insulating regions is a feature proper of their phase separation characteristics.²⁸ In fact, their dielectric properties showed a behavior compatible with a MW description, as was already reported.^{26,29,30}

In summary, the T dependence of the RS properties of a Ag/LSCO interface was reported. A detailed study of the IV characteristics at different temperatures for both LRS and HRS is presented, allowing the development of an equivalent circuit model based on a non-linear PF element and two ohmic resistances. This model captures the non-trivial electrical behavior of the Ag/LSCO junction that we believe gives a general representation of other metal/perovskite oxide memristors. This model also allows to envision details of the microscopic constitution of the interfacial zone and to understand which are the specific changes produced upon the pulsing treatments.

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* corresponding author (acha@df.uba.ar)

- [†] University of Buenos Aires, Conicet and Erasmus scholarships. Present address: Correlated Electronics Group, AIST Tsukuba Central 5, 1-1-1 Higashi, Tsukuba, Ibaraki 305-8565, Japan.
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